

**Amendments to the Claims:**

The following listing of claims will replace all prior versions, and listings, of claims in the application:

1. (Currently Amended) A quartz ring for use in a plasma processing apparatus, comprising:

an inner perimeter;

a main surface extending outwardly from the inner perimeter;

a first portion around the inner perimeter, the first portion having a flat first

region on the main surface; and

a second portion adjacent to an outer perimeter of the first portion having a smaller thickness than that of the first portion, the second portion having a second region adjacent to the first region on the main surface, the second region having a height lower than that of the first ~~region~~; region extending outwardly from the outer perimeter of the first portion to the outer perimeter of the quartz ring;

wherein the first region and the second region are regions of the quartz ring and are parallel to each other.

2. (Previously Presented) The quartz ring according to claim 1, wherein the second region is flat and is parallel to the first region.

3. (Previously Presented) The quartz ring according to claim 1, further comprising a flat second surface opposite to the main surface, the second surface being parallel to the first region.

4. (Previously Presented) The quartz ring according to claim 1, wherein a difference of the heights of the first region and the second region is about 0.1 mm to about 2 mm.

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